

The documentation and process conversion measures necessary to comply with this revision shall be completed by 9 June 2004.

NCH-POUND

MIL-PRF-19500/631B
 9 March 2004
 SUPERSEDING
 MIL-PRF-19500/631A
 20 August 1998

PERFORMANCE SPECIFICATION SHEET

SEMICONDUCTOR DEVICE, FIELD EFFECT RADIATION HARDENED
 (TOTAL DOSE AND SINGLE EVENT EFFECTS) TRANSISTORS, N-CHANNEL
 SILICON, TYPES 2N7395, 2N7396, 2N7397, AND 2N7398,
 JANSD AND JANSR

This specification is approved for use by all Departments and Agencies of the Department of Defense.

* The requirements for acquiring the product described herein shall consist of this specification sheet and MIL-PRF-19500.

1. SCOPE

1.1 Scope. This specification covers the performance requirements for a N-channel, enhancement-mode, MOSFET, radiation hardened (total dose and single event characterization), power transistors. One level of product assurance is provided for each device type as specified in MIL-PRF-19500.

1.2 Physical dimensions. See figure 1, (similar to TO-205).

1.3 Maximum ratings. Unless otherwise specified, $T_A = +25^\circ\text{C}$.

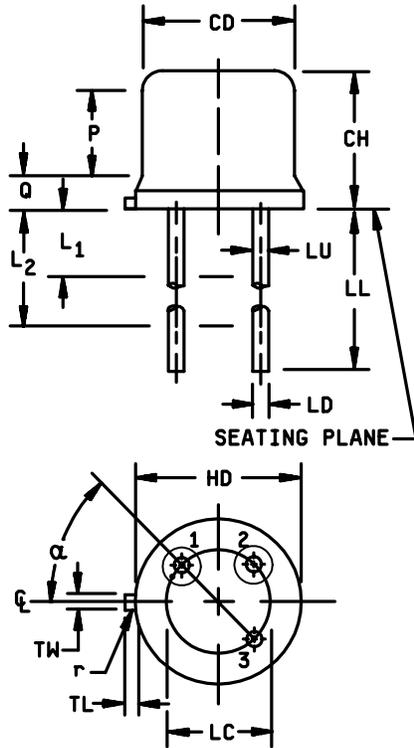
Type	P_T (1) $T_C = +25^\circ\text{C}$	P_T $T_A = +25^\circ\text{C}$	V_{DS}	V_{DG}	V_{GS}	I_{D1} (2) (3) $T_C = +25^\circ\text{C}$	I_{D2} (2) (3) $T_C = +100^\circ\text{C}$	I_S (2)	I_{DM}	T_J and T_{STG}	V_{ISO} 70,000 ft. altitude
	<u>W</u>	<u>W</u>	<u>V dc</u>	<u>V dc</u>	<u>V dc</u>	<u>A dc</u>	<u>A dc</u>	<u>A dc</u>	<u>A (pk)</u>	<u>°C</u>	<u>V dc</u>
2N7395	25	10	100	100	± 20	8.0	5.0	8.0	24	-55	N/A
2N7396			200	200		5.0	3.0	5.0	15	to	N/A
2N7397			250	250		4.0	2.0	4.0	12	+150	250
2N7398			500	500		2.0	1.0	2.0	6		500

- (1) Derate linearly 0.2 W/°C for $T_C > +25^\circ\text{C}$;
 (2) The following formula derives the maximum theoretical I_D limit. I_D is limited by package and internal wires and may be limited by pin diameter:

$$I_D = \sqrt{\frac{T_{JM} - T_C}{(R_{\theta JC}) \times (R_{DS(on)} \text{ at } T_{JM})}}$$

- (3) See figure 2, maximum drain current graphs.

* Comments, suggestions, or questions on this document should be addressed to Defense Supply Center, Columbus, ATTN: DSCC-VAC, P.O. Box 3990, Columbus, OH 43216-5000, or emailed to Semiconductor@dsccl.dla.mil. Since contact information can change, you may want to verify the currency of this address information using the ASSIST Online database at <http://www.dodssp.daps.mil/>.



Ltr	Dimensions			
	Inches		Millimeters	
	Min	Max	Min	Max
CD	.315	.335	8.01	8.50
CH	.160	.180	4.07	4.57
HD	.350	.370	8.89	9.39
LC	.190	.210	4.83	5.33
LD	.016	.023	0.41	0.58
LL	.500	.560	12.7	14.22
LU	.016	.021	0.41	0.53
L1		.050		1.27
L2		.250		6.35
P		.100		2.54
Q		.040		1.02
r		.010		0.018
TL	.029	.045	0.74	1.14
TW	.028	.034	0.72	0.86
α	45° TP		45° TP	
Term 1	Source			
Term 2	Gate			
Term 3	Drain			

NOTES:

1. Dimensions are in inches.
2. Millimeters are given for general information only.
3. Terminals 1 and 2 are isolated from case, terminal 3 is butt welded to stem base.
4. The preferred measurements used herein are the metric units. However, this transistor was designed using inch-pound units of measurement. In case of conflicts between the metric and inch-pound units, the inch-pound units shall be the rule.
- * 5. In accordance with ASME Y14.5M, diameters are equivalent to ϕx symbology.

* FIGURE 1. Dimensions and configuration (similar to TO-205).

* 1.4 Primary electrical characteristics at $T_C = +25^\circ\text{C}$.

Type	Min $V_{(BR)DSS}$ $V_{GS} = 0$ $I_D = 1.0 \text{ mA dc}$	$V_{GS(TH)1}$ $V_{DS} \geq V_{GS}$ $I_D = 1.0 \text{ mA dc}$	Max I_{DSS1} $V_{GS} = 0$ $V_{GS} = 80$ percent of rated V_{DS}	Max $r_{DS(on)}$ (1) $V_{GS} = 12V$		$R_{\theta JC}$ Max	$I_{AS} = I_{DM}$
				$T_J = +25^\circ\text{C}$ at I_{D2}	$T_J = +125^\circ\text{C}$ at I_{D2}		
	<u>V dc</u>	<u>V dc</u> Min Max	<u>$\mu\text{A dc}$</u>	<u>Ω</u>	<u>Ω</u>	<u>$^\circ\text{C/W}$</u>	<u>A (pk)</u>
2N7395	100	1.5 4.0	25	0.23	0.36	5.00	24
2N7396	200			0.46	0.81		15
2N7397	250			0.61	1.11		12
2N7398	500			2.50	4.80		6

(1) Pulsed (see 4.5.1).

2. APPLICABLE DOCUMENTS

* 2.1 General. The documents listed in this section are specified in sections 3, 4, or 5 of this specification. This section does not include documents cited in other sections of this specification or recommended for additional information or as examples. While every effort has been made to ensure the completeness of this list, document users are cautioned that they must meet all specified requirements of documents cited in sections 3, 4, or 5 of this specification, whether or not they are listed.

2.2 Government documents.

* 2.2.1 Specifications, standards, and handbooks. The following specifications, standards, and handbooks form a part of this document to the extent specified herein. Unless otherwise specified, the issues of these documents are those cited in the solicitation or contract.

DEPARTMENT OF DEFENSE SPECIFICATIONS

MIL-PRF-19500 - Semiconductor Devices, General Specification for.

DEPARTMENT OF DEFENSE STANDARDS

MIL-STD-750 - Test Methods for Semiconductor Devices.

* (Copies of these documents are available online at <http://assist.daps.dla.mil/quicksearch/> or <http://www.dodssp.daps.mil/> or from the Standardization Document Order Desk, 700 Robbins Avenue, Building 4D, Philadelphia, PA 19111-5094.)

2.3 Order of precedence. In the event of a conflict between the text of this document and the references cited herein, the text of this document takes precedence. Nothing in this document, however, supersedes applicable laws and regulations unless a specific exemption has been obtained.

3. REQUIREMENTS

* 3.1 General. The individual item requirements shall be as specified in MIL-PRF-19500 and as modified herein.

* 3.2 Qualification. Devices furnished under this specification shall be products that are manufactured by a manufacturer authorized by the qualifying activity for listing on the applicable qualified manufacturers list before contract award (see 4.2 and 6.3).

* 3.3 Abbreviations, symbols, and definitions. Abbreviations, symbols, and definitions used herein shall be as specified in MIL-PRF-19500 and as follows.

nC.....Coulomb.
I_{AS}.....Rated avalanche current, non-repetitive.

* 3.4 Interface and physical dimensions. Interface and physical dimensions shall be as specified in MIL-PRF-19500, and on figure 1.

* 3.4.1 Lead material and finish. Lead material shall be Kovar or Alloy 52; a copper core or plated core is permitted. Lead finish shall be solderable as defined in MIL-PRF-19500, MIL-STD-750, and herein. Where a choice of lead finish is desired, it shall be specified in the acquisition document (see 6.2).

3.5 Electrostatic discharge protection. The devices covered by this specification require electrostatic discharge protection.

3.5.1 Handling. MOS devices must be handled with certain precautions to avoid damage due to the accumulation of static charge. However, the following handling practices are recommended (see 3.5).

- a. Devices should be handled on benches with conductive handling devices.
- b. Ground test equipment, tools and personnel handling devices.
- c. Do not handle devices by the leads.
- d. Store devices in conductive foam or carriers.
- e. Avoid use of plastic, rubber or silk in MOS areas.
- f. Maintain relative humidity above 50 percent if practical.
- g. Care should be exercised during test and troubleshooting to apply not more than maximum rated voltage to any lead.
- h. Gate must be terminated to source, $R \leq$ or 100 k Ω , whenever bias voltage is applied drain to source.

3.6 Electrical performance characteristics. Unless otherwise specified herein, the electrical performance characteristics are as specified in 1.3, 1.4, and table I.

* 3.7 Electrical test requirements. The electrical test requirements shall be as specified in table I.

* 3.8 Marking. Marking shall be in accordance with MIL-PRF-19500. At the option of the manufacturer, marking of the country of origin may be omitted from the body of the transistor but shall be retained on the initial container.

* 3.9 Workmanship. Semiconductor devices shall be processed in such a manner as to be uniform in quality and shall be free from other defects that will affect life, serviceability, or appearance.

4. VERIFICATION

4.1 Classification of inspections. The inspection requirements specified herein are classified as follows:

- a. Qualification inspection (see 4.2).
- b. Screening (see 4.3).
- c. Conformance inspection (see 4.4 and tables I, II, and III).

* 4.2 Qualification inspection. Qualification inspection shall be in accordance with MIL-PRF-19500.

* 4.2.1 Group E qualification. Group E inspection shall be performed for qualification or re-qualification only. In case qualification was awarded to a prior revision of the specification sheet that did not request the performance of table III tests, the tests specified in table III herein shall be performed on the first inspection lot of this revision to maintain qualification.

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* 4.3 Screening (JANS only). Screening shall be in accordance with table IV of MIL-PRF-19500, and as specified herein. The following measurements shall be made in accordance with table I herein. Devices that exceed the limits of table I herein shall not be acceptable.

Screen (see table IV of MIL-PRF-19500) (1) (2)	Measurement
	JANS
(3)	Gate stress test (see 4.3.1)
(3)	Method 3470 of MIL-STD-750, (see 4.3.2)
(3) 3c	Method 3161 of MIL-STD-750, (see 4.3.3)
9	I_{GSSF1} , I_{GSSR1} , I_{DSS1} , subgroup 2 of table I herein.
10	Method 1042 of MIL-STD-750, test condition B
11	I_{GSSF1} , I_{GSSR1} , I_{DSS1} , $r_{DS(ON)}$, $V_{GS(TH)}$ Subgroup 2 of table I herein. $\Delta I_{GSSF1} = \pm 20$ nA dc or ± 100 percent of initial value, whichever is greater. $\Delta I_{GSSR1} = \pm 20$ nA dc or ± 100 percent of initial value, whichever is greater. $\Delta I_{DSS1} = \pm 25$ μ A dc or ± 100 percent of initial value, whichever is greater.
12	Method 1042 of MIL-STD-750, test condition A
13	Subgroups 2 and 3 of table I herein $\Delta I_{GSSF1} = \pm 20$ nA dc or ± 100 percent of initial value, whichever is greater. $\Delta I_{GSSR1} = \pm 20$ nA dc or ± 100 percent of initial value, whichever is greater. $\Delta I_{DSS1} = \pm 25$ μ A dc or ± 100 percent of initial value, whichever is greater. $\Delta r_{DS(ON)1} = \pm 20$ percent of initial value. $\Delta V_{GS(TH)1} = \pm 20$ percent of initial value.

- (1) At the end of the test program, I_{GSSF1} , I_{GSSR1} , and I_{DSS1} , are measured.
- (2) An out-of-family program to characterize I_{GSSF1} , I_{GSSR1} , I_{DSS1} , and $V_{GS(th)1}$ shall be invoked.
- (3) Shall be performed anytime before screen 9.

* 4.3.1 Gate stress test. Apply $V_{GS} = 30$ V minimum for $t = 250$ μ s minimum.

* 4.3.2 Single pulse avalanche energy (E_{AS}).

- a. $I_{AS} = I_{DM}$.
- b. $L = 0.1$ mH.
- c. $E_{AS} = 1/2 LI_{AS}^2$.
- d. $V_{DD} = 50$ V to 150 V dc.
- e. Initial junction temperature = 25°C, -5°C, +10°C.

* 4.3.3 Thermal impedance (ΔV_{SD} measurement). The ΔV_{SD} measurement shall be performed in accordance with method 3161 of MIL-STD-750. The ΔV_{SD} conditions (I_H and V_H) and maximum limit shall be derived by each vendor from the thermal response curves (see figure 3) and shall be specified in the certificate of conformance prior to qualification. The following parameter measurements shall apply:

- a. Measuring current (I_M) 10 mA.
- b. Heating time (t_H) 10 ms.
- c. Measurement time delay (t_{MD}) 30 - 60 μ s.
- d. Sample window time (t_{SW}) 10 μ s maximum.

* 4.4 Conformance inspection. Conformance inspection shall be in accordance with MIL-PRF-19500.

4.4.1 Group A inspection. Group A inspection shall be conducted in accordance with table V of MIL-PRF-19500 and table I herein.

* 4.4.2 Group B inspection. Group B inspection shall be conducted in accordance with the conditions specified for subgroup testing in table VIa (JANS) of MIL-PRF-19500 and as follows. End-point electrical measurements shall be in accordance with the applicable steps of table IV herein.

<u>Subgroup</u>	<u>Method</u>	<u>Condition</u>
B3	1051	Temp. cycling, test condition G, 100 cycles.
B3	2077	SEM.
B4	1042	Intermittent operation life, condition D, 2,000 cycles. No heat sink nor or forced-air cooling on the device shall be permitted during the on cycle. $t_{ON} = 30$ seconds minimum.
B5	1042	Accelerated steady-state reverse bias, condition A, $V_{DS} =$ rated; $T_A = +175^\circ\text{C}$; $t = 120$ hours, minimum.
B5	1042	Accelerated steady-state gate bias, condition B, $V_{GS} =$ rated; $T_A = +175^\circ\text{C}$; $t = 24$ hours.
B5	2037	Bond strength; test condition A.
B6	3161	Thermal resistance, see 4.5.2.

* 4.4.3 Group C inspection. Group C inspection shall be conducted in accordance with the conditions specified for subgroup testing in table VII of MIL-PRF-19500 and as follows. Electrical measurements (end-points) and delta requirements shall be in accordance with the applicable steps of table IV herein.

<u>Subgroup</u>	<u>Method</u>	<u>Condition</u>
C2	2036	Terminal strength, test condition E, weight = 8 oz., 3 arcs.
C5	3161	See 4.5.2.
C6	1042	Intermittent operation life, test condition D, 6,000 cycles; 1 cycle = 30 seconds minimum.

4.4.4 Group D inspection. Group D inspection shall be conducted in accordance with table VIII of MIL-PRF-19500 and table II herein.

* 4.4.4.1 Design parameters. Not tested on a per lot basis. Design shall be such that the devices shall be capable of meeting the requirements herein.

* 4.4.5 Group E inspection. Group E inspection shall be conducted in accordance with the conditions specified for subgroup testing in table IX of MIL-PRF-19500 and as specified in table III herein. Electrical measurements (end-points) and delta requirement shall be in accordance with the applicable steps of table IV herein.

4.5 Methods of inspection. Methods of inspection shall be as specified in the appropriate tables and as follows.

4.5.1 Pulse measurements. Conditions for pulse measurement shall be as specified in section 4 of MIL-STD-750.

4.5.2 Thermal resistance. Thermal resistance measurements shall be performed in accordance with method 3161 of MIL-STD-750. The maximum limit of $R_{\theta JC} = 5.0 \text{ }^{\circ}\text{C/W}$. The following parameters shall apply:

- a. Measuring current(I_M) 10 mA.
- b. Drain heating current (I_H) 1 A (min).
- c. Heating time (t_H) Steady-state (see method 3161 of MIL-STD-750).
- d. Drain-source heating voltage (V_H)...25 V.
- e. Measurement time delay (t_{MD}) 30 to 60 μs .
- f. Sample window time (t_{SW}) 10 μs maximum.

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* TABLE I. Group A inspection.

Inspection 1/	MIL-STD-750		Symbol	Limits		Unit
	Method	Condition		Min	Max	
<u>Subgroup 1</u>						
Visual and mechanical inspection	2071					
<u>Subgroup 2</u>						
Thermal impedance	3161	See 4.3.3	ΔV_{SD}			
Breakdown voltage drain to source	3407	Bias condition C, $V_{GS} = 0$ V, $I_D = 1$ mA dc	$V_{(BR)DSS}$			
2N7395				100		V dc
2N7396				200		V dc
2N7397				250		V dc
2N7398				500		V dc
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}$, $I_D = 1$ mA dc	$V_{GS(th)}$	1.5	4.0	V dc
Gate current	3411	Bias condition C, $V_{DS} = 0$ V, $V_{GS} = +20$ V dc	I_{GSSF1}		+100	nA dc
Gate current	3411	$V_{GS} = -20$ V dc, bias condition C, $V_{DS} = 0$ V	I_{GSSR1}		-100	nA dc
Drain current	3413	$V_{GS} = 0$ V dc, bias condition C, $V_{DS} = 80$ percent of rated V_{DS} ,	I_{DSS1}		25	μ A dc
Static drain to source on-state resistance	3421	$V_{GS} = 12$ V dc, condition A, pulsed (see 4.5.1), $I_D = I_{D2}$	$r_{DS(on)1}$			
2N7395					0.23	Ω
2N7396					0.46	Ω
2N7397					0.61	Ω
2N7398					2.50	Ω
Static drain to source on-state voltage	3405	$V_{GS} = 12$ V dc, condition A, pulsed (see 4.5.1), $I_D = I_{D1}$	$V_{DS(on)}$			
2N7395					1.93	V dc
2N7396					2.42	V dc
2N7397					2.56	V dc
2N7398					5.25	V dc
Forward voltage	4011	$V_{GS} = 0$ V dc, condition A, pulsed (see 4.5.1), $I_D = I_{D1}$	V_{SD}		1.8	V dc
<u>Subgroup 3</u>						
High temperature operation		$T_C = T_J = +125^\circ\text{C}$				
Gate current	3411	$V_{GS} = +20$ V dc and -20 V dc, bias condition C, $V_{DS} = 0$ V	I_{GSS2}		± 200	nA dc
Drain current	3413	$V_{GS} = 0$ V dc, bias condition C, $V_{DS} = 80$ percent of rated V_{DS}	I_{DSS2}		0.25	mA dc

See footnote at end of table.

* TABLE I. Group A inspection - Continued.

Inspection <u>1/</u>	MIL-STD-750		Symbol	Limits		Unit
	Method	Condition		Min	Max	
<u>Subgroup 3</u> - Continued						
Static drain to source on-state resistance 2N7395 2N7396 2N7397 2N7398	3421	$V_{GS} = 12 \text{ V dc}$, condition A, pulsed (see 4.5.1), $I_D = I_{D2}$	$r_{DS(on)2}$		0.36 0.81 1.11 4.80	Ω Ω Ω Ω
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}$, $I_D = 1 \text{ mA dc}$	$V_{GS(th)2}$	0.5		V dc
Low temperature operation		$T_C = T_J = -55^\circ\text{C}$				
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}$, $I_D = 1 \text{ mA dc}$	$V_{GS(th)3}$		5.0	V dc
<u>Subgroup 4</u>						
Switching time test	3472	$I_D = I_{D1}$, $V_{GS} = 12 \text{ V dc}$ $R_G = 7.5 \Omega$, $V_{DD} = 50 \text{ percent of rated } V_{DS}$				
Turn-on delay time 2N7395 2N7396 2N7397 2N7398			$t_{D(on)}$		70 65 60 80	ns ns ns ns
Rise time 2N7395 2N7396 2N7397 2N7398			t_R		220 150 140 100	ns ns ns ns
Turn-off delay time 2N7395 2N7396 2N7397 2N7398			$t_{D(off)}$		100 120 120 150	ns ns ns ns
Fall time 2N7395 2N7396 2N7397 2N7398			t_f		90 85 95 140	ns ns ns ns

See footnote at end of table.

* TABLE I. Group A inspection - Continued.

Inspection <u>1/</u>	MIL-STD-750		Symbol	Limits		Unit				
	Method	Condition		Min	Max					
<u>Subgroup 5</u>	3474	See figure 4, $t_p = 10$ ms min. $V_{DS} = 80$ percent of max. rated V_{DS} ($V_{DS} \leq 200$ V)								
Safe operating area test (high voltage)										
Electrical measurements		See table IV, steps 1, 2, 3, 4, 5, 6, and 7.								
<u>Subgroup 6</u>										
Not applicable										
<u>Subgroup 7</u>	3471	Condition B								
Gate charge										
On-state gate charge							QG(on)			
2N7395								43	nC	
2N7396								38	nC	
2N7397								40	nC	
2N7398								35	nC	
Gate to source charge							QGS			
2N7395								8.7	nC	
2N7396								8.4	nC	
2N7397		8.4	nC							
2N7398		6.7	nC							
Gate to drain charge	QGD									
2N7395		22	nC							
2N7396		20	nC							
2N7397		20	nC							
2N7398		16	nC							
Reverse recovery time	3473	$di/dt = 100$ A/ μ s, $V_{DD} \leq 30$ V $I_D = I_{D1}$	tRR							
2N7395				330	ns					
2N7396				360	ns					
2N7397				400	ns					
2N7398				390	ns					

1/ For sampling plan, see MIL-PRF-19500.

TABLE II. Group D inspection.

Inspection <u>1/</u> <u>2/</u> <u>3/</u> <u>4/</u>	MIL-STD-750		Symbol	Pre-irradiation limits		Post irradiation limits		Units
	Method	Conditions		Min.	Max.	Min.	Max.	
<u>Subgroup 1</u>								
Not applicable								
<u>Subgroup 2</u>		$T_C = +25^\circ\text{C}$						
Steady state total dose irradiation (V_{GS} bias) <u>4/</u>	1019	$V_{GS} = 12\text{ V},$ $V_{DS} = 0\text{ V}$						
Steady state total dose irradiation (V_{DS} bias)	1019	$V_{GS} = 0\text{ V},$ $V_{DS} = 80\text{ percent of rated } V_{DS}$						
Breakdown voltage drain to source 2N7395 2N7396 2N7397 2N7398	3407	$V_{GS} = 0\text{ V},$ $I_D = 1\text{ mA dc},$ Bias condition C	$V_{(BR)DSS}$	100 200 250 500		100 200 250 500		V dc V dc V dc V dc
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}, I_D = 1\text{ mA dc}$	$V_{GS(TH)1}$	1.5	4.0	1.5	4.0	V dc
Gate current	3411	$V_{GS} = +20\text{ V dc and } -20\text{ V dc},$ $V_{DS} = 0\text{ V},$ Bias condition C	I_{GSS1}		± 100		± 100	nA dc
Drain current	3413	$V_{GS} = 0\text{ V}, V_{DS} = 80\text{ percent of}$ rated $V_{DS},$ Bias condition C	I_{DSS1}		25		25	$\mu\text{A dc}$
Static drain to source on-state resistance 2N7395 2N7396 2N7397 2N7398	3421	$V_{GS} = 12\text{ V dc},$ condition A, pulsed (see 4.5.1), $I_D = I_{D2}$	$r_{DS(ON)1}$		0.23 0.46 0.61 2.50		0.23 0.46 0.61 2.50	Ω Ω Ω Ω
Static drain to source on-state voltage 2N7395 2N7396 2N7397 2N7398	3405	$V_{GS} = 12\text{ V dc},$ condition A, Pulsed (see 4.5.1), $I_D = I_{D1}$	$V_{DS(ON)}$		1.93 2.42 2.56 5.25		1.93 2.42 2.56 5.25	V dc V dc V dc V dc

1/ For sampling plan see MIL-PRF-19500.

2/ Electrical specifications are for 'D' and 'R' rad levels.

3/ Group D qualification may be performed prior to lot formation. Wafers qualified to these group D QCI requirements may be used for any other specification utilizing the same die design.

4/ At the manufacturers option, group D samples need not be subjected to all the screening tests, but shall be assembled in its qualified package or in any qualified package that the manufacturer has data to correlate the performance to the designated package.

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* TABLE III. Group E inspection (all quality levels) for qualification or re-qualification only.

Inspection <u>1/ 2/ 3/ 4/ 5/</u>	MIL-STD-750		Qualification and large lot conformance inspection
	Method	Conditions	
<u>Subgroup 1</u>			12 devices c = 0
Temperature cycle	1051	Condition G, 500 cycles	
Hermetic seal Fine leak Gross leak	1071	Test conditions G or H Test conditions C or D	
Electrical measurements		See table IV, steps 1, 2, 3, 4, 5, 6, and 7	
<u>Subgroup 2 1/</u>			12 devices c = 0
Steady-state gate bias	1042	Condition B, 1,000 hours	
Electrical measurements		See table IV, steps 1, 2, 3, 4, 5, 6, and 7	
Steady-state reverse bias	1042	Condition A, 1,000 hours	
Electrical measurements		See table IV, steps 1, 2, 3, 4, 5, 6, and 7	
<u>Subgroup 3</u>			3 devices, c = 0
DPA	2102		
<u>Subgroup 4</u>			Sample size N/A
Thermal impedance curves		Each supplier shall submit their (typical) design maximum thermal impedance curves. In addition, the optimal test conditions and $Z_{\theta JX}$ limit shall be provided to the qualifying activity in the qualification report	
<u>Subgroup 5</u>			5 devices c = 0
Barometric pressure test (not required for $V_{BR(DSS)} \leq 200$ V) 2N7397 2N7398	1001	Test condition C $V_{DS} = 250$ V; $I_{(ISO)} < 0.25$ mA $V_{DS} = 500$ V; $I_{(ISO)} < 0.25$ mA	
<u>Subgroup 6</u>			3 devices c = 0
ESD	1020	Not required for devices classified as ESD class 1.	

See footnotes at end of table.

MIL-PRF-19500/631B

* TABLE III. Group E inspection (all quality levels) for qualification or re-qualification only - Continued.

Inspection <u>1/ 2/ 3/ 4/ 5/</u>	MIL-STD-750		Qualification and large lot conformance inspection
	Method	Conditions	
<u>Subgroup 8</u> Electrical measurements <u>3/</u> SEE effect testing <u>4/</u>	1080	See table IV, steps 3 and 4	3 devices <u>5/</u> c = 0
2N7395		See figure 5, Fluence = $3e5 \pm 20$ percent ions/cm ² Flux = $5e3$ to $2e4$ ions/cm ² sec Beam energy = 260 to 300 MeV Temperature = $25^{\circ}\text{C} \pm 5^{\circ}\text{C}$ LET = 26 to 30 MeV-cm ² /mg Ion range = 40 to 45 microns Insitu bias conditions: $V_{DS} = 100$ V and $V_{GS} = -20$ V LET = 36 to 40 MeV-cm ² /mg Ion range = 35 to 40 microns Insitu bias conditions: $V_{DS} = 100$ V and $V_{GS} = -10$ V $V_{DS} = 80$ V and $V_{GS} = -15$ V $V_{DS} = 50$ V and $V_{GS} = -20$ V	
2N7396		LET = 26 to 30 MeV-cm ² /mg Ion range = 40 to 45 microns Insitu bias conditions: $V_{DS} = 200$ V and $V_{GS} = -20$ V LET = 36 to 40 MeV-cm ² /mg Ion range = 35 to 40 microns Insitu bias conditions: $V_{DS} = 200$ V and $V_{GS} = -5$ V $V_{DS} = 160$ V and $V_{GS} = -10$ V $V_{DS} = 100$ V and $V_{GS} = -15$ V $V_{DS} = 40$ V and $V_{GS} = -20$ V	
2N7397		LET = 26 to 30 MeV-cm ² /mg Ion range = 40 to 45 microns Insitu bias conditions: $V_{DS} = 250$ V and $V_{GS} = -20$ V LET = 36 to 40 MeV-cm ² /mg Ion range = 35 to 40 microns Insitu bias conditions: $V_{DS} = 250$ V and $V_{GS} = -5$ V $V_{DS} = 200$ V and $V_{GS} = -10$ V $V_{DS} = 125$ V and $V_{GS} = -15$ V $V_{DS} = 50$ V and $V_{GS} = -20$ V	
2N7398		LET = 26 to 30 MeV-cm ² /mg Ion range = 40 to 45 microns Insitu bias conditions: $V_{DS} = 500$ V and $V_{GS} = -15$ V $V_{DS} = 450$ V and $V_{GS} = -20$ V LET = 36 to 40 MeV-cm ² /mg Ion range = 35 to 40 microns Insitu bias conditions: $V_{DS} = 500$ V and $V_{GS} = -5$ V $V_{DS} = 400$ V and $V_{GS} = -10$ V $V_{DS} = 100$ V and $V_{GS} = -15$ V	

See footnote at end of table.

* TABLE III. Group E inspection (all quality levels) for qualification or re-qualification only - Continued.

Inspection <u>1/ 2/ 3/ 4/ 5/</u>	MIL-STD-750		Qualification and large lot conformance inspection
	Method	Conditions	
<p><u>Subgroup 8</u> - continued.</p> <p>Electrical measurements <u>3/</u></p> <p><u>Subgroup 9</u></p> <p>Commutating diode for safe operating area test procedure for measuring dv/dt during reverse recovery of power MOSFET transistors or insulated gate bipolar transistors</p>	3476	See table IV, steps 3 and 4	22 devices c = 0

- 1/ A separate sample for each test may be pulled.
- 2/ Group E qualification of single event effect testing may be performed prior to lot formation. Wafers qualified to these group E QCI requirements may be used for any other specification utilizing the same die design.
- 3/ As a minimum, gate to source leakages and drain to source leakage are to be examined to verify the electrical performance of the DUT prior to and after test. At the manufacturer's option, the remaining static tests in table IV, with the exception of step 8, may be performed.
- 4/ Devices passing a given combination of drain and gate voltage for an LET of 36 to 40 MeV-cm²/mg qualify the same conditions for an LET of 26 to 30 MeV-cm²/mg.
- 5/ This sampling plan applies to each bias condition defined.

* TABLE IV. Group A, B, C and E electrical and delta measurements.

Step	Inspection 1/ 2/	MIL-STD-750		Symbol	Limits		Units
		Method	Conditions		Min	Max	
1.	Breakdown voltage drain to source	3407	$V_{GS} = 0 \text{ V}$, $I_D = 1 \text{ mA dc}$, Bias condition C	$V_{(BR)DSS}$			
	2N7395				100		V dc
	2N7396				200		V dc
	2N7397				250		V dc
2N7398	500		V dc				
2.	Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}$, $I_D = 1 \text{ mA dc}$	$V_{GS(TH)1}$	1.5	4.0	V dc
3.	Gate current	3411	$V_{GS} = +20 \text{ V}$ and -20 V dc , Bias condition C, $V_{DS} = 0 \text{ V}$	I_{GSS1}		± 100	nA dc
4.	Drain current	3413	$V_{GS} = 0 \text{ V dc}$, Bias condition C, $V_{DS} = 80 \text{ percent of rated } V_{DS}$	I_{DSS1}		25	$\mu\text{A dc}$
5.	Static drain to source on-state resistance	3421	$V_{GS} = 12 \text{ V dc}$, condition A, pulsed (see 4.5.1), $I_D = I_{D2}$	$r_{DS(ON)1}$			
	2N7395					0.23	Ω
	2N7396					0.46	Ω
	2N7397					0.61	Ω
2N7398		2.50	Ω				
6.	Static drain to source on-state voltage	3405	$V_{GS} = 12 \text{ V dc}$, condition A, pulsed (see 4.5.1), $I_D = I_{D1}$	$V_{DS(ON)}$			
	2N7395					1.93	V dc
	2N7396					2.42	V dc
	2N7397					2.56	V dc
2N7398		5.25	V dc				
7.	Forward voltage	4011	$V_{GS} = 0 \text{ V dc}$, condition A, pulsed (see 4.5.1), $I_D = I_{D1}$	V_{SD}		1.8	V dc
8.	Thermal impedance	3161	See 4.3.3	ΔV_{SD}		125	mV

1/ The electrical measurements for table VIa (JANS) of MIL-PRF-19500 are as follows:

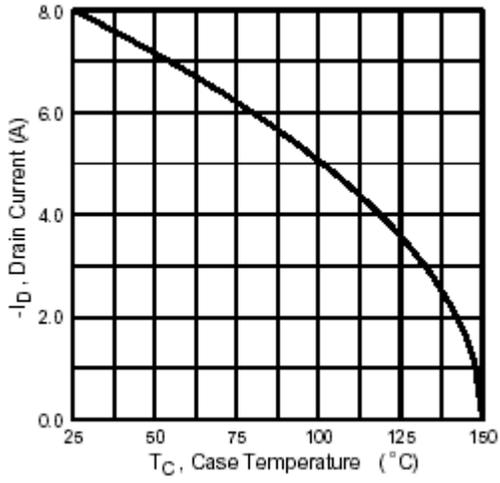
- a. Subgroup 3, see table IV herein, steps 1, 2, 3, 4, 5, 6, and 7.
- b. Subgroup 4, see table IV herein, steps 1, 2, 3, 4, 5, 6, 7, and 8.
- c. Subgroup 5, see table IV herein, steps 1, 2, 3, 4, 5, 6, and 7.

2/ The electrical measurements for table VII of MIL-PRF-19500 are as follows:

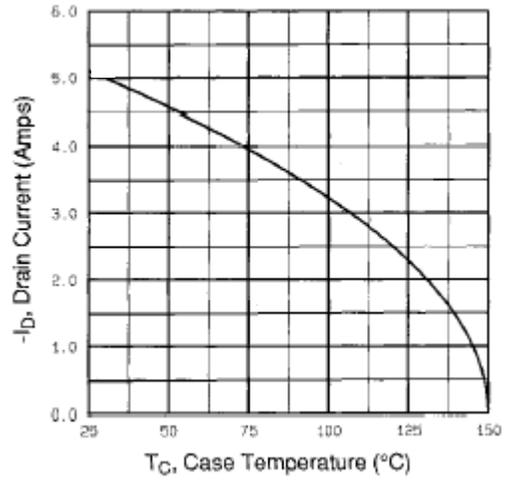
- a. Subgroup 2 and 3, see table IV herein, steps 1, 2, 3, 4, 5, 6, and 7.
- b. Subgroup 6, see table IV herein, steps 1, 2, 3, 4, 5, 6, 7, and 8.

3/ The electrical measurements for table IX of MIL-PRF-19500 are as follows:

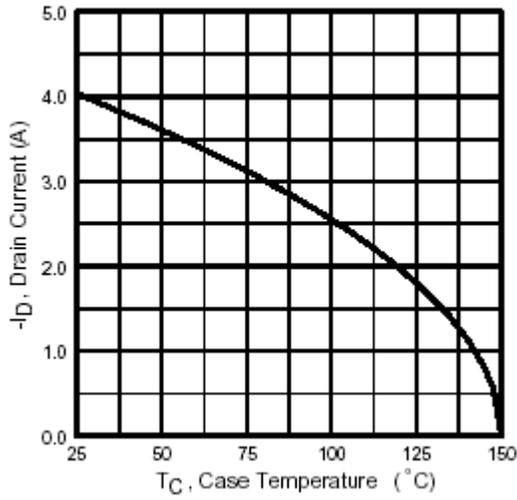
- a. Subgroups 1 and 2, see table IV herein, steps 1, 2, 3, 4, 5, 6, 7, and 8.
- b. Subgroup 8, see table IV herein, steps 3 and 4.



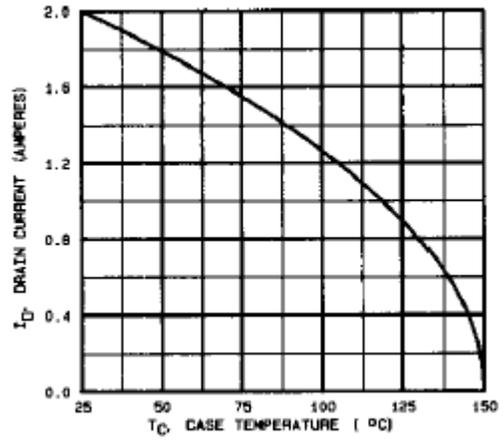
2N7395



2N7396

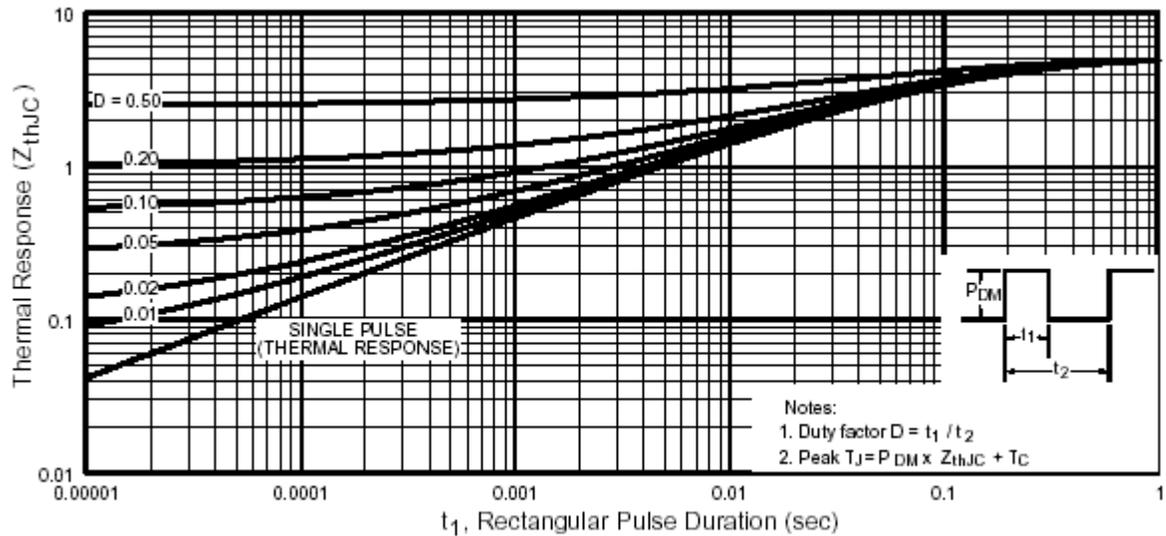


2N7397



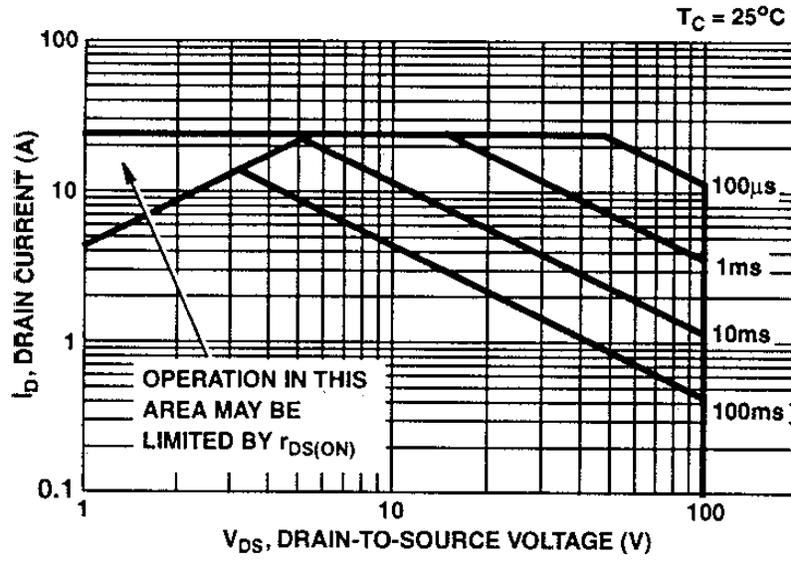
2N7398

* FIGURE 2. Maximum drain current vs case temperature graphs.

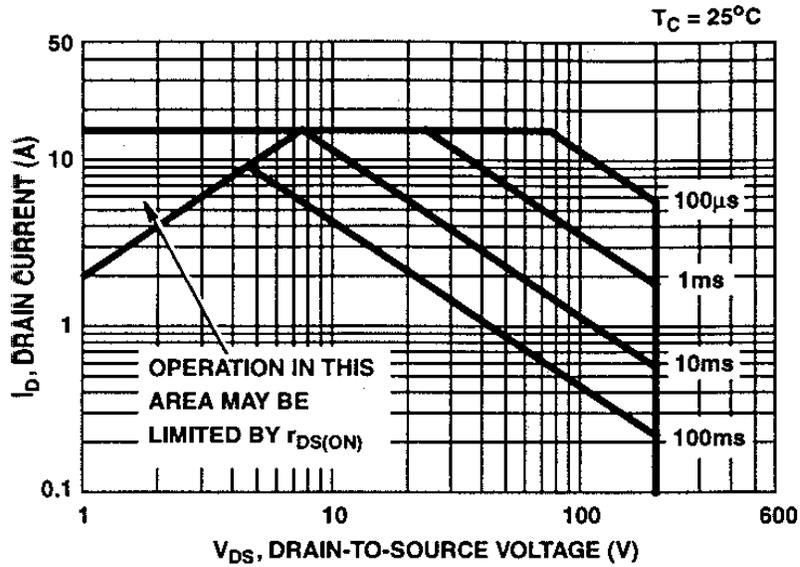


* FIGURE 3. Thermal response curves.

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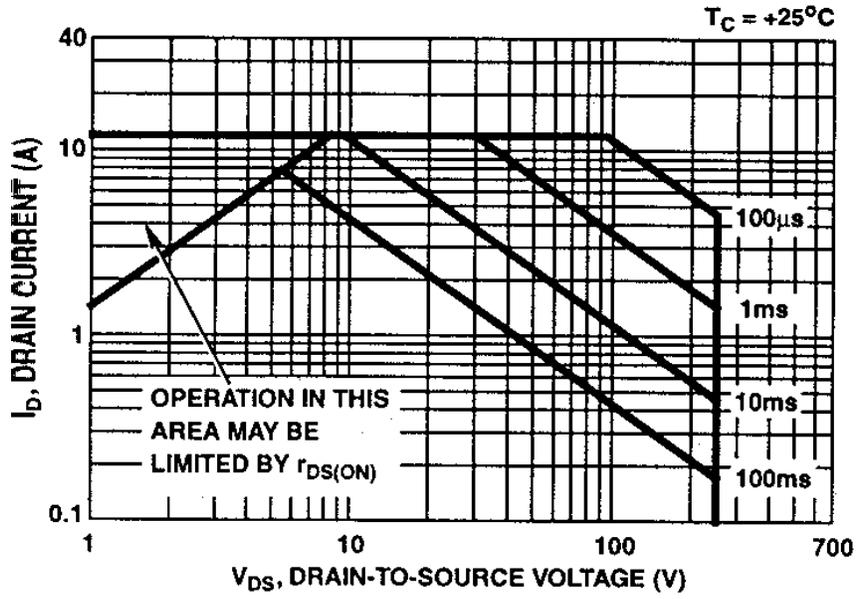


2N7396

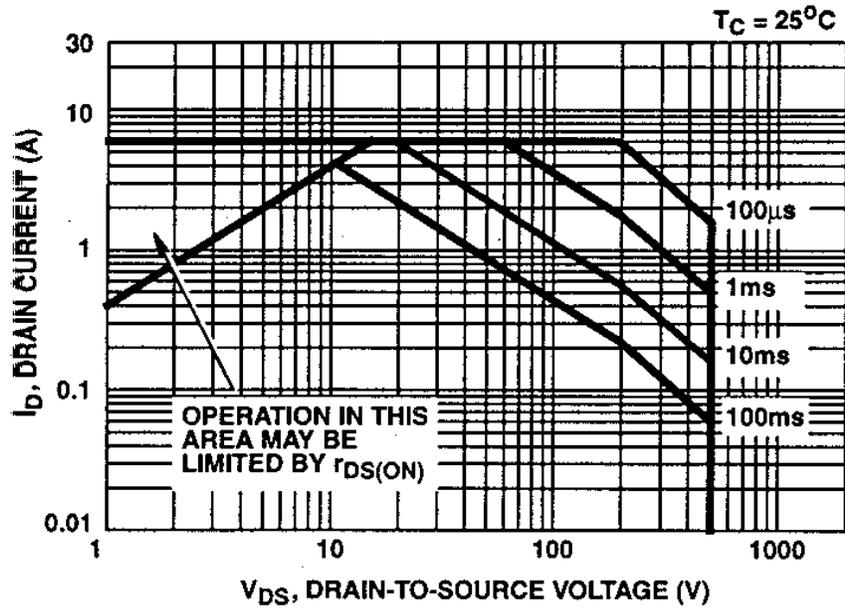


* FIGURE 4. Safe operating area graphs.

2N7397

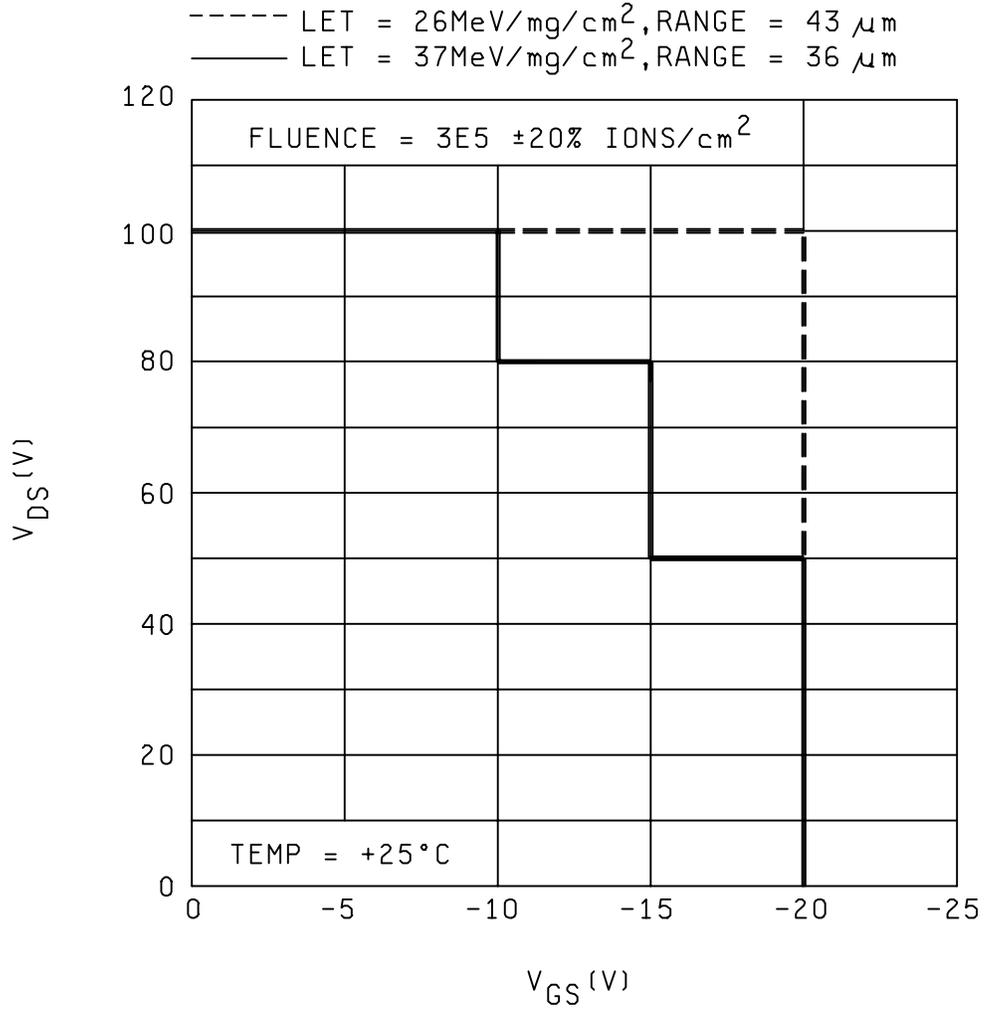


2N7398



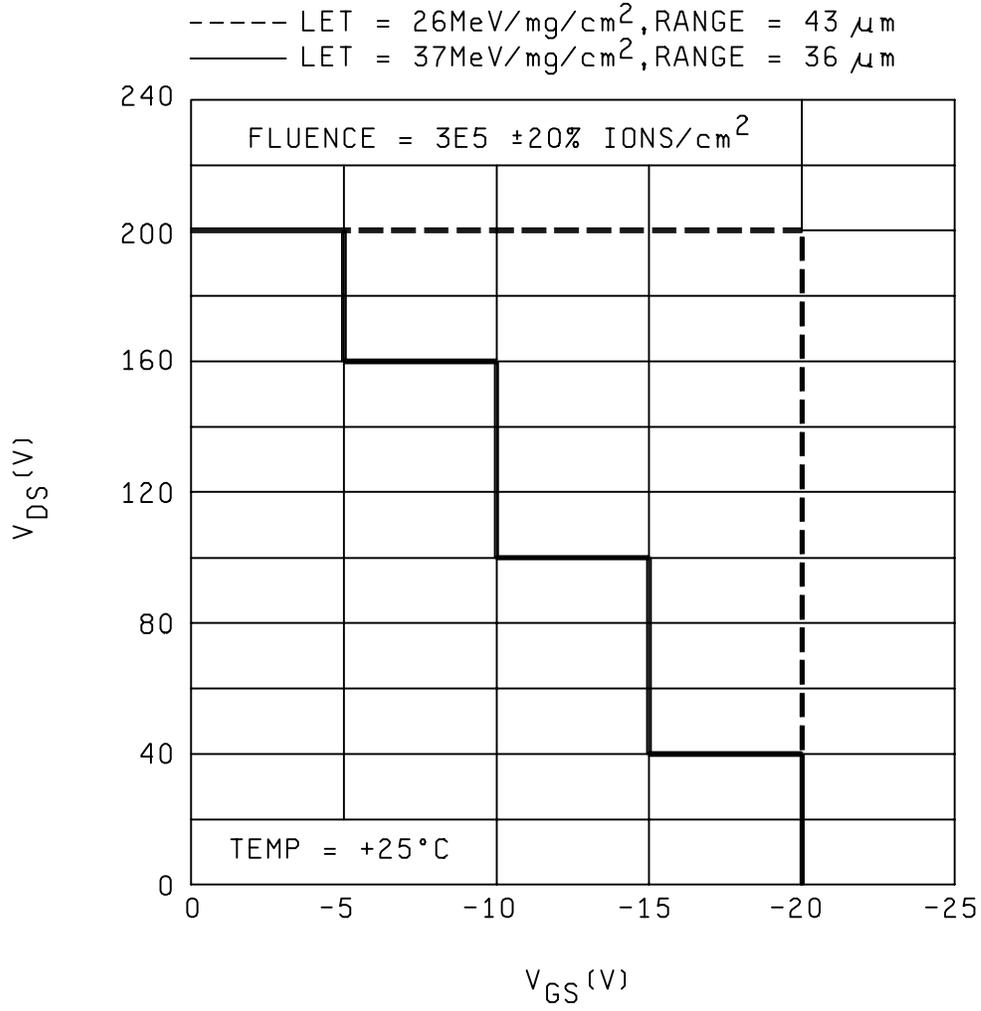
* FIGURE 4. Safe operating area graphs - Continued.

2N7395



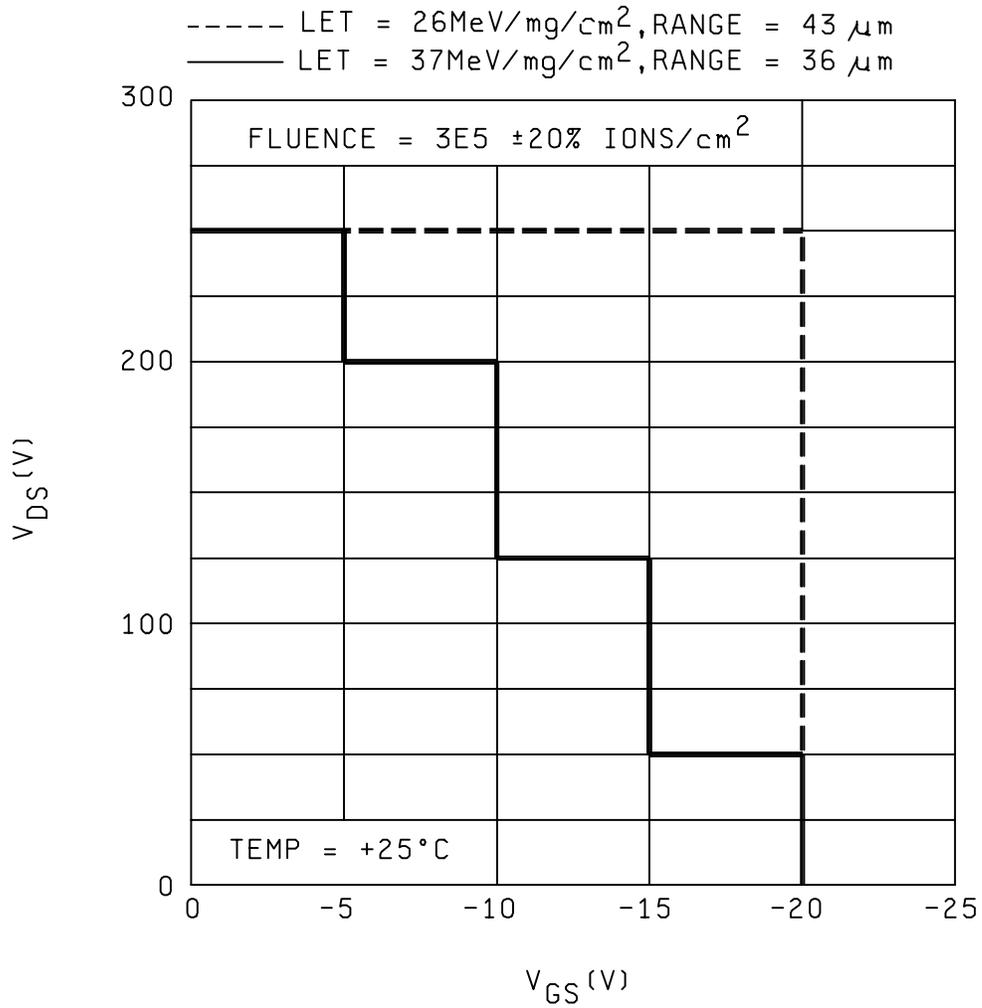
* FIGURE 5. Single event effects safe operating area graphs.

2N7396



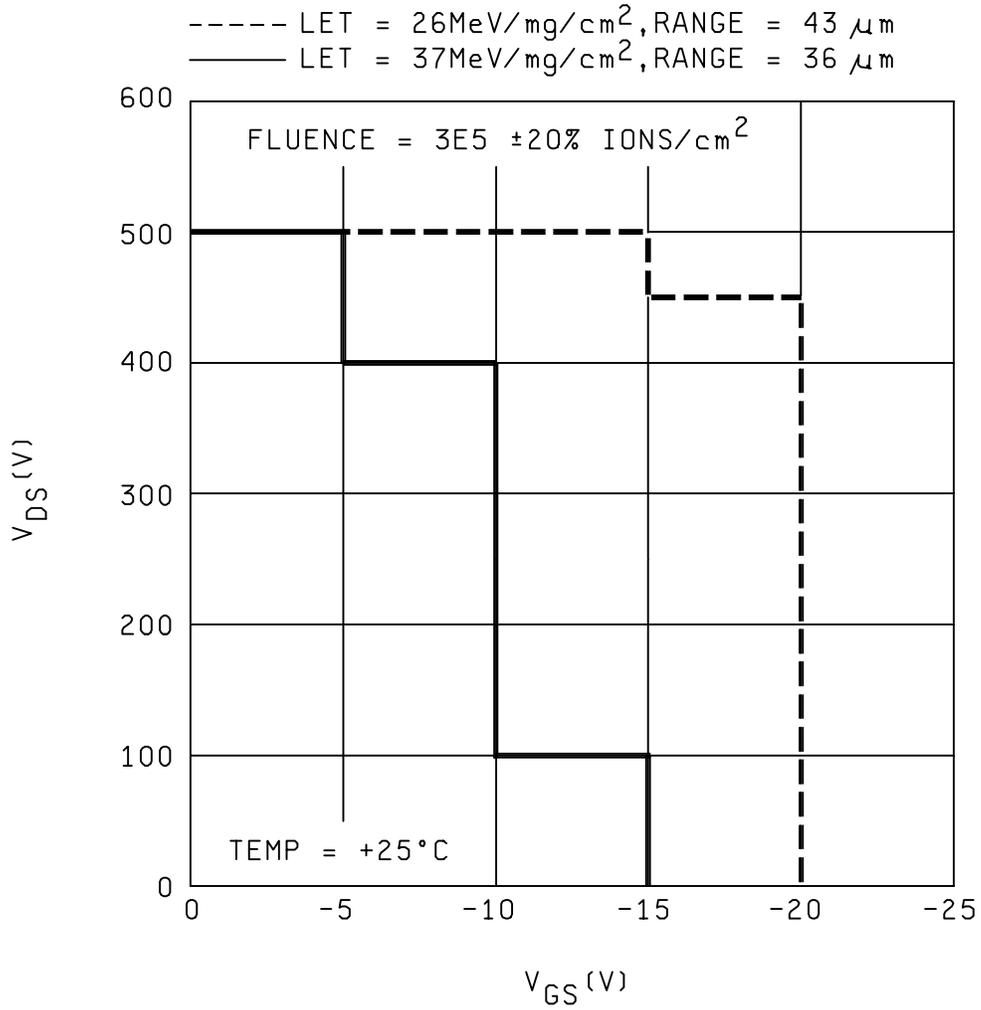
* FIGURE 5. Single event effects safe operating area graphs - Continued.

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* FIGURE 5. Single event effects safe operating area graphs - Continued.

2N7398



* FIGURE 5. Single event effects safe operating area graphs - Continued.

5. PACKAGING

* 5.1 Packaging. For acquisition purposes, the packaging requirements shall be as specified in the contract or order (see 6.2). When actual packaging of materiel is to be performed by DoD or in-house contractor personnel, these personnel need to contact the responsible packaging activity to ascertain packaging requirements. Packaging requirements are maintained by the Inventory Control Point's packaging activities within the Military Service or Defense Agency, or within the Military Service's system commands. Packaging data retrieval is available from the managing Military Department's or Defense Agency's automated packaging files, CD-ROM products, or by contacting the responsible packaging activity.

6. NOTES

(This section contains information of a general or explanatory nature that may be helpful, but is not mandatory.)

* 6.1 Intended use. The notes specified in MIL-PRF-19500 are applicable to this specification.

* 6.2 Acquisition requirements. Acquisition documents should specify the following:

- a. Title, number, and date of this specification.
- b. Packaging requirements (see 5.1).
- c. Lead material and finish may be specified (see 3.4.1).
- d. Product assurance level and type designator.

* 6.3 Qualification. With respect to products requiring qualification, awards will be made only for products which are, at the time of award of contract, qualified for inclusion in Qualified Manufacturers List (QML No. 19500) whether or not such products have actually been so listed by that date. The attention of the contractors is called to these requirements, and manufacturers are urged to arrange to have the products that they propose to offer to the Federal Government tested for qualification in order that they may be eligible to be awarded contracts or orders for the products covered by this specification. Information pertaining to qualification of products may be obtained from Defense Supply Center, Columbus, ATTN: DSCC/VQE, P.O. Box 3990, Columbus, OH 43216-5000 or e-mail vqe.chief@dla.mil.

* 6.4 Substitution information. Devices covered by this specification are substitutable for the manufacturer's and user's Part or Identifying Number (PIN). This information in no way implies that manufacturer's PINs are substitutable for the military PIN.

Generic P/N	Military P/N
SL130	2N7395
SL230	2N7396
SL234	2N7397
SL430	2N7398

* 6.5 Changes from previous issue. The margins of this specification are marked with asterisks to indicate where changes from the previous issue were made. This was done as a convenience only and the Government assumes no liability whatsoever for any inaccuracies in these notations. Bidders and contractors are cautioned to evaluate the requirements of this document based on the entire content irrespective of the marginal notations and relationship to the last previous issue.

Custodians:
Army - CR
Navy - EC
Air Force - 11
NASA - NA
DLA - CC

Preparing activity:
DLA - CC

(Project 5961-2849)

* NOTE: The activities listed above were interested in this document as of the date of this document. Since organizations and responsibilities can change, you should verify the currency of the information above using the ASSIST Online database at <http://www.dodssp.daps.mil/>.